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April 19, 2007

AMENDMENT AFTER
ALLOWANCE

Atty Docket No. :	ICLA7109-R
Appl No. :	10/603,924
Filing Date :	June 24, 2003
Pages :	Cover + 12

BY FACSIMILE ONLY

Fax No. :	571-273-8300
Attention :	EXAMINER: NGUYEN, THANH T.
Group Unit :	2813
From :	Jawei Huang, Reg. No. 43,330
MESSAGE :	Enclosed herewith is a Amendment After Allowance with amended drawings in 12 pages.

Sir:

I hereby certify that this correspondence is being facsimile transmitted to the Patent and Trademark Office on April 19, 2007 at the above indicated fax number.

Sign By: Michelle Chang
Michelle Chang

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Application No.: 10/603,924

Doclet No.: JCLA7109-R

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:)	Examiner :	NGUYEN,
THANH T.)	Art Unit :	2813
Serial No.: 10/603,924)	Docket No. :	JCLA7109-R
Filed : June 24, 2003)		
For :)		
METHOD OF REMOVING)		
CONTAMINANTS FROM A)		
SILICON WAFER AFTER)		
CHEMICAL-MECHANICAL)		
POLISHING OPERATION)		

AMENDMENTS AFTER ALLOWANCE UNDER 37 CFR 1.312

MAIL STOP AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir,

The Notice of Allowance dated January 24, 2007 has been carefully considered. In response thereto, please enter the following amendments and consider the remarks hereinafter.